

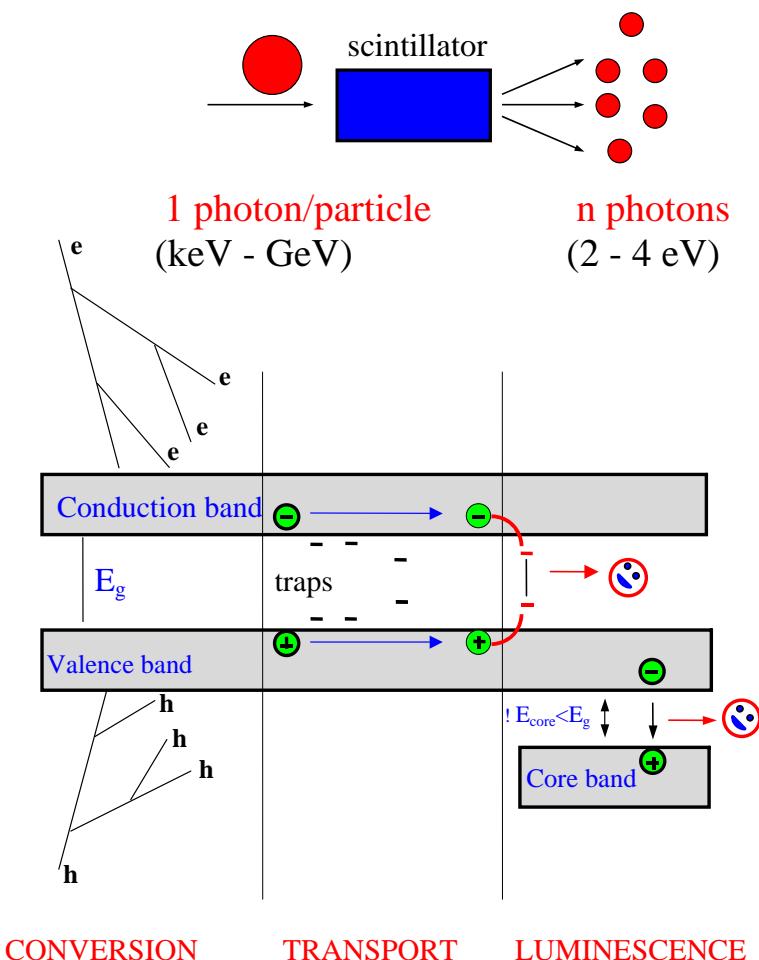
# Halide Crystal Growth

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# Principle of scintillators



## Scintillators

- detectors of radiation
- **convertors** the energy of ionizing radiation into **VUV/UV/visible light**

## Application

- medical imaging, homeland security, high energy physics, etc.

## Transport

- **shallow traps/defects** influence transport of charge carriers to luminescence centers
- **slow components** in the scintillation decay

## Ternary alkali metal halides

general formula



A = Li, Na, K, Rb, Cs

M<sup>4+</sup> = Ti, Zr, Hf, Pt, Sn, Se, Te

X = F, Cl, Br, I



m.p. [°C]	826
Melting	congruent
Phase transition [°C]	no
Density [g/cm <sup>3</sup> ]	3.8
Crystal. structure	cubic
Space group	Fm-3m

### doping

(UO<sub>2</sub>)<sup>2+</sup>, Te<sup>4+</sup>, Sn<sup>4+</sup>, Re<sup>4+</sup> Os<sup>4+</sup>, Mo<sup>3+</sup>, Ir<sup>4+</sup>, Na<sup>+</sup>, Ce<sup>3+</sup>, Eu<sup>2+</sup>

### Application of Cs<sub>2</sub>HfCl<sub>6</sub>

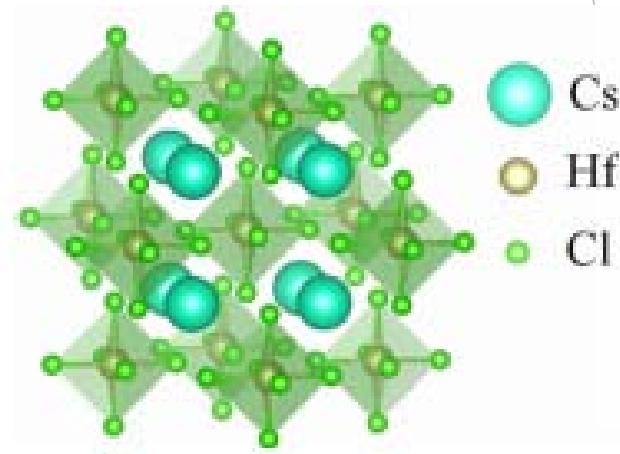
- ✓ as cost-effective radiation detector (scintillators)
- ✓ highly proportional light yield
- ✓ even without doping with any intentional activator

# Properties

	$\text{Cs}_2\text{HfCl}_6$	Tl:NaI	Tl:CsI	Eu:SrI <sub>2</sub>	Ce:LaBr <sub>3</sub>
Density [g/cm <sup>3</sup> ]	3.8	3.4	4.5	4.6	5.3
m.p. [°C]	826	661	621	538	783
Cryst. structure	Cubic	Cubic	Cubic	Orthorhom.	Hex.
Eg [eV]	6.3	5.8	6.1	5.5	5.9
Zeff	58	50	51	49	47
Emission max. [nm]	380	410	540	430	360
Decay time [ns]	300 (5%); 4400 (95%)	230	1100	600-2400	35
Light yield [ph/MeV]	54,000	38,000	66,000	80,000-120,000	61,000
Resolution [%] @662 eV	3-4	7	6	3-4	3
Hygroscopicity	low	yes	yes	yes	yes

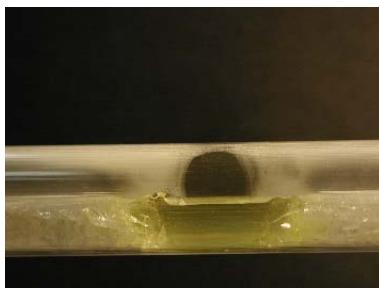
# $\text{Cs}_2\text{HfCl}_6$ growth

- ▶ Hygroscopic starting materials ( $\text{CsCl}$ ,  $\text{HfCl}_4$ )
- ▶ Purification of starting materials
- ▶  $\text{HfCl}_4$  low sublimation point ( $320^\circ\text{C}$ ) vs.  $\text{Cs}_2\text{HfCl}_6$  congruent melting point ( $826^\circ\text{C}$ )
- ▶ High vapor pressure in ampoules

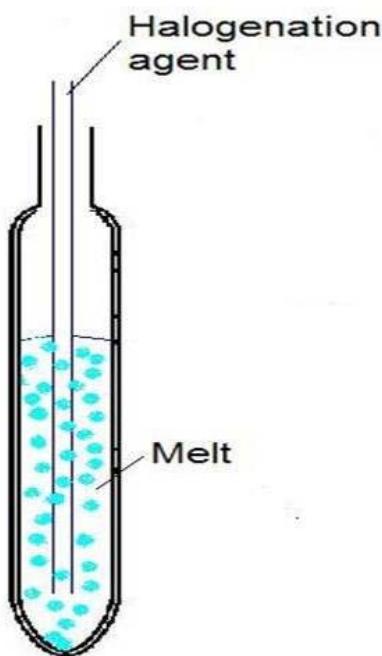


# Material refinement

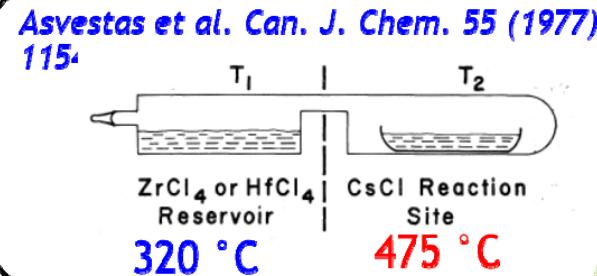
- ▶ CsCl
- ▶ Zone refining



- ▶ Halogenating agents

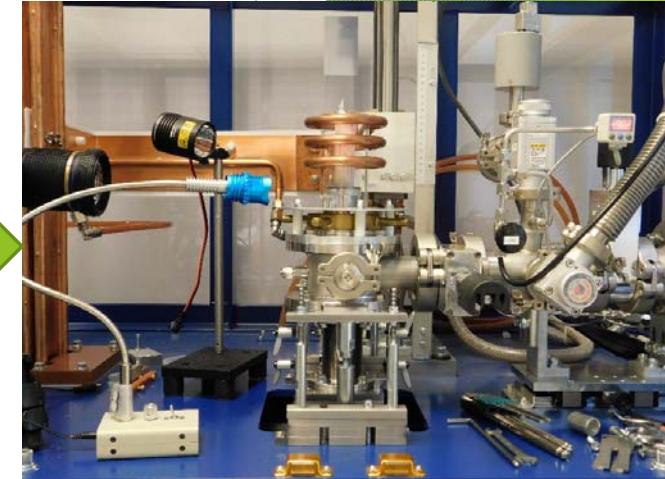
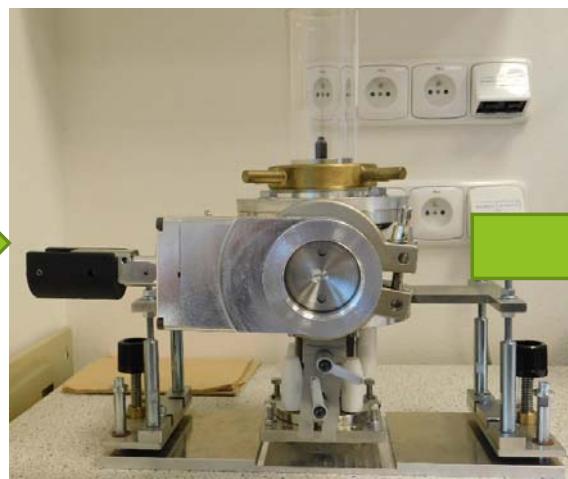


- ▶ HfCl<sub>4</sub>
- ▶ Resublimation



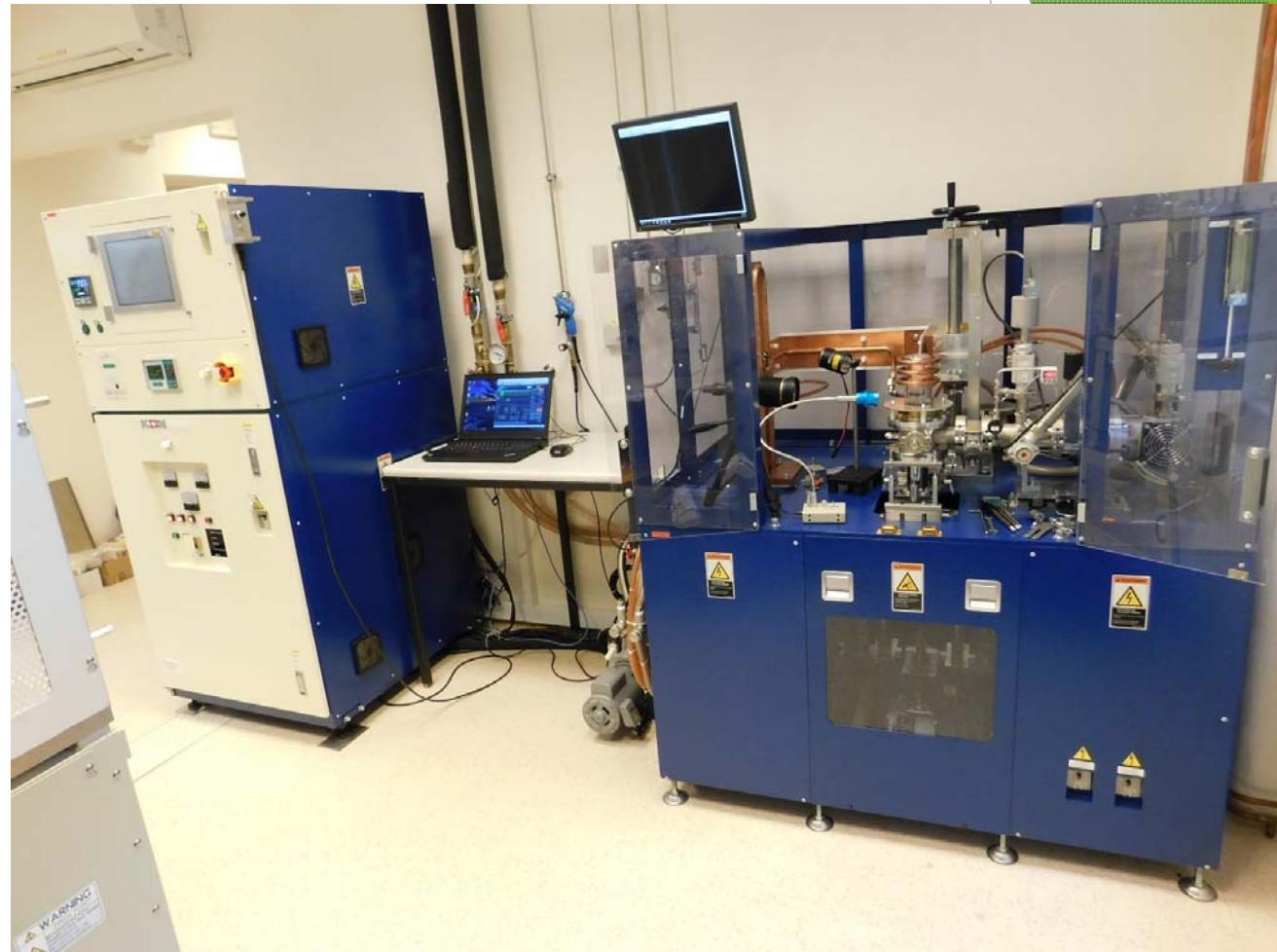
- ▶ Halogenating agents

# Sample preparation and transport



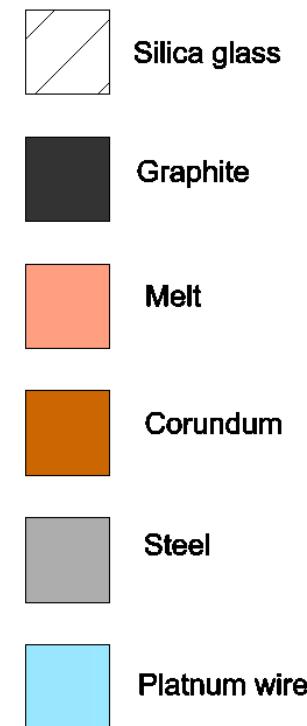
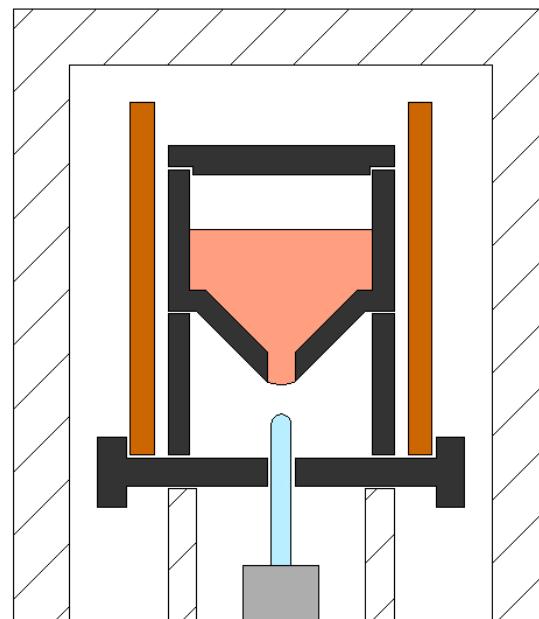
# Halide $\mu$ -pulling-down apparatus

- ▶ Enclosed growth ampule
- ▶ Growth atmosphere control
- ▶ RF heating
- ▶ Remote control
- ▶ Capable of VB growth

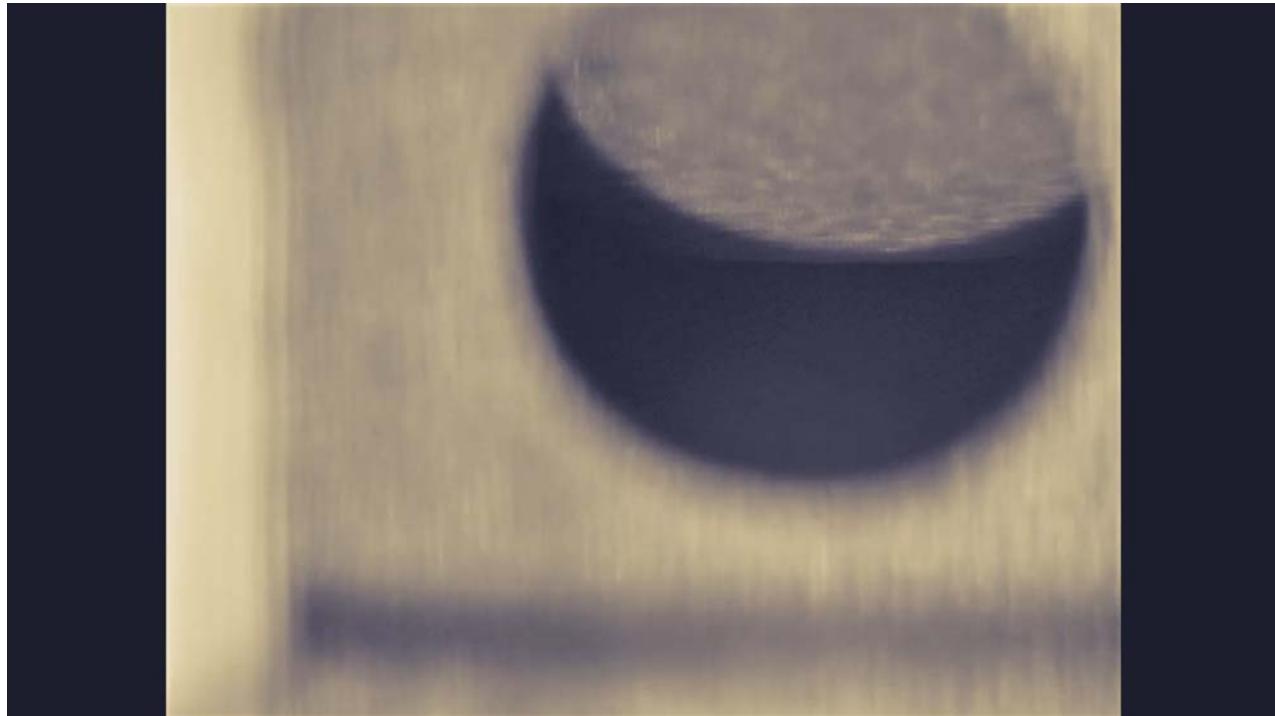


# Micro-pulling-down (mPD)

- ▶ Seeded growth
- ▶ RF heating with graphite crucible
- ▶ Crystal shape control
- ▶ Pulling rates 0.6 - 6 mm/h
- ▶ Diameter: 2-3 mm
- ▶ Length: 20 - 40 mm

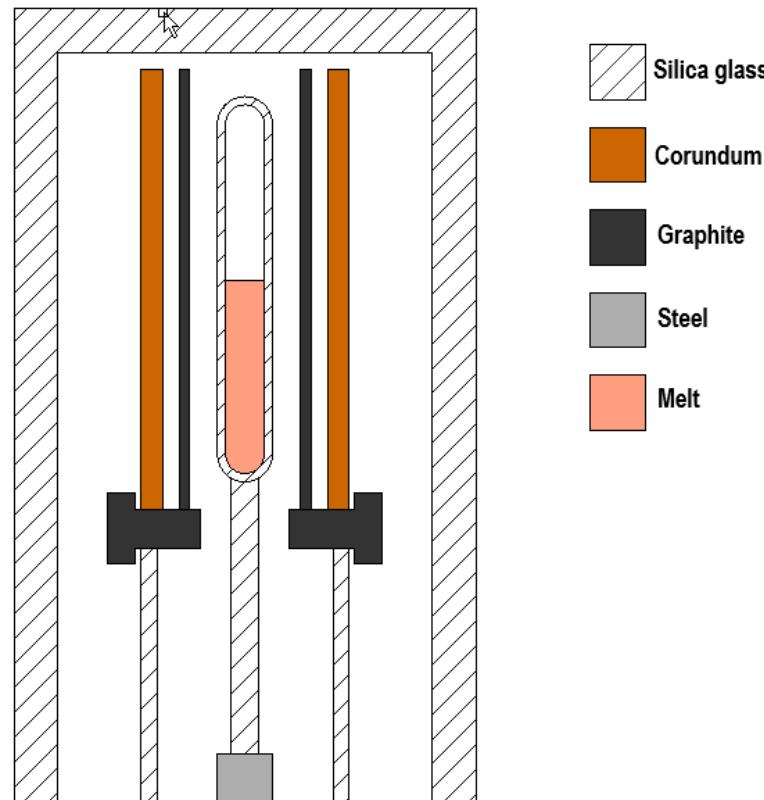


# mPD growth



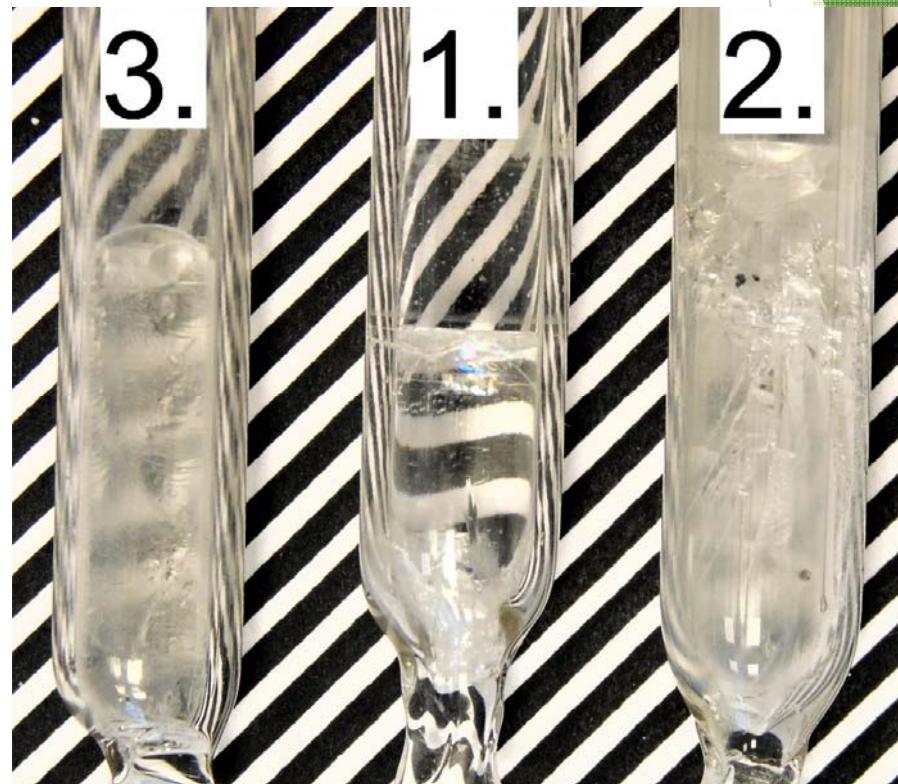
# Vertical Bridgman (VB) method

- ▶ Unseeded growth
- ▶ RF heating with graphite heater
- ▶ Silica glass ampules
- ▶ Pulling rates 0.6 - 1.2 mm/h
- ▶ Diameter: 7 mm
- ▶ Length: 20 - 40 mm



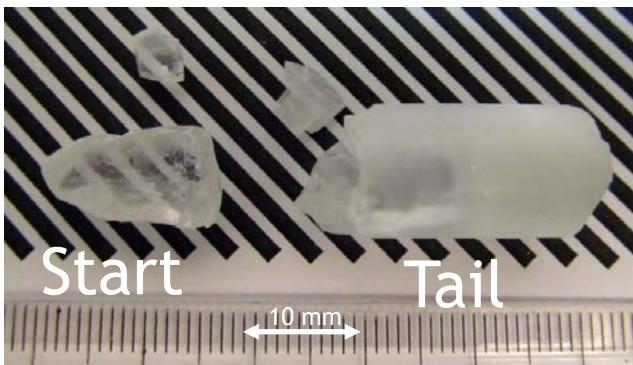
# NaCl VB growth

- ▶ Cubic crystal structure
- ▶ Melting point 801 °C
- ▶ 3 samples
- ▶ 0.6 and 1.2 mm/h pulling rate
- ▶ 1. Nitrogen atmosphere
- ▶ 2. Perforated ampule
- ▶ 3. Growth under vacuum

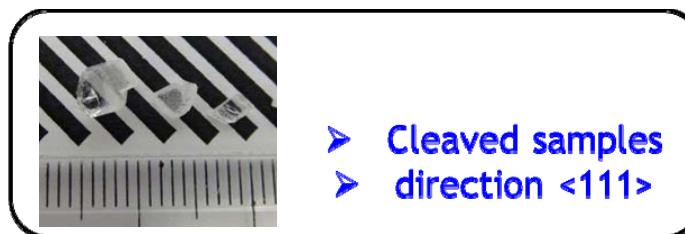


# As-grown $\text{Cs}_2\text{HfCl}_6$ crystal

- vertical Bridgman growth
- charges of  $\text{Cs}_2\text{HfCl}_6$  from opened system: 2, 3, and 4
- 12 x 40 mm (D x L), colorless
- polycrystalline, homogeneous grains
- tip and bulk - transparent
- tail - nontransparent



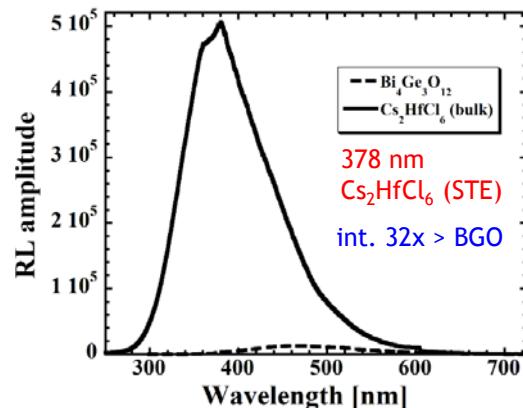
XRD



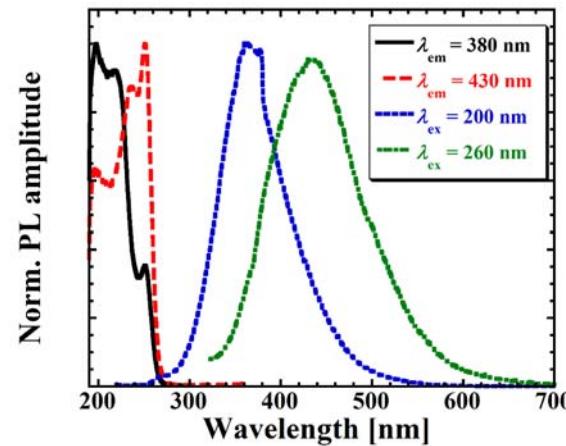
Comp.	Start [mol%]	Tail [mol%]
$\text{Cs}_2\text{HfCl}_6$	97	22
CsCl	3	78

## Cs<sub>2</sub>HfCl<sub>6</sub>, single crystal, START

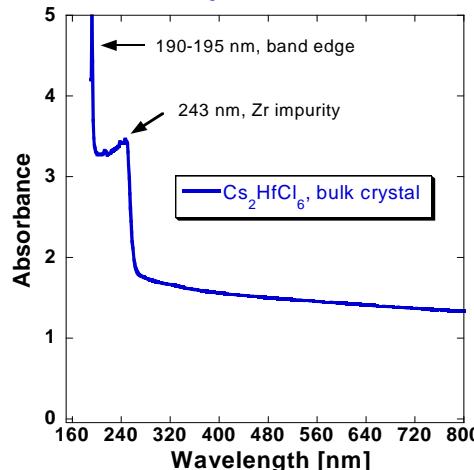
### Radioluminescence, RT



### PL, PLE spectra, RT

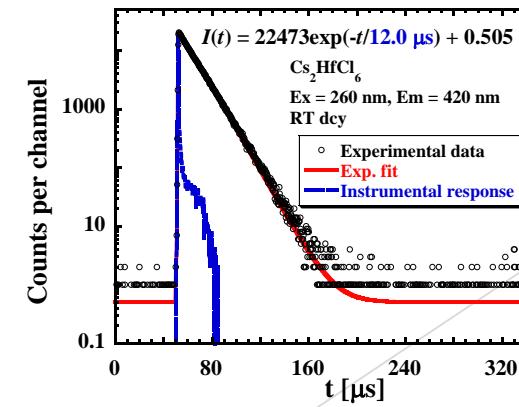
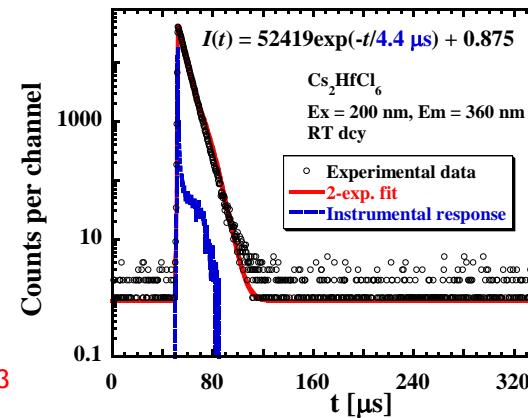


### Absorption, RT



- ✓ band edge 195 nm -> **band gap 6.3 eV**
- ✓ Zr absorption 243 nm

✓ 360 nm - em. of STE in Cs<sub>2</sub>HfCl<sub>6</sub>, PL decay 4.4  $\mu$ s  
✓ 440 nm - em. of STE of Zr impurity, PL decay 12.0  $\mu$ s



# Future plans

- ▶ Development of CHC growth by VB method
- ▶ Growth of undoped CHC single crystals
- ▶ Monovalent ns<sup>2</sup> cations doping (Tl<sup>+</sup>, In<sup>+</sup>)
- ▶ Tetravalent cations doping (Ti<sup>4+</sup>, Zr<sup>4+</sup>, Sn<sup>4+</sup>, Mo<sup>4+</sup>, W<sup>4+</sup>)
- ▶ Anion admixture (Cs<sub>2</sub>HfCl<sub>6-x</sub>Br<sub>x</sub> etc.)
- ▶ Optical measurements (RL, PL, PLE, LY, DT, RT)
- ▶ Stability measurements (hygroscopicity)

Thank you for your attention!